

| L Number | Hits | Search Text | DB | Time stamp |
|----------|------|---|---|------------------|
| - | 7948 | ((438/624) or (438/634) or (438/637) or (438/737) or (438/738) or (438/740) or (438/743) or (438/744) or (438/761) or (438/763) or (438/786) or (438/787) or (438/791)).CCLS. | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2003/03/17 11:05 |
| - | 1311 | ((((438/624) or (438/634) or (438/637) or (438/737) or (438/738) or (438/740) or (438/743) or (438/744) or (438/761) or (438/763) or (438/786) or (438/787) or (438/791))).CCLS.) and (etch\$3 adj stop\$4) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2003/03/17 11:06 |
| - | 448 | (((438/624) or (438/634) or (438/637) or (438/737) or (438/738) or (438/740) or (438/743) or (438/744) or (438/761) or (438/763) or (438/786) or (438/787) or (438/791))).CCLS.) and (etch\$3 adj stop\$4)) and (silicon adj nitride) and (silicon adj dioxide) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2003/03/17 11:07 |
| - | 461 | (((438/624) or (438/634) or (438/637) or (438/737) or (438/738) or (438/740) or (438/743) or (438/744) or (438/761) or (438/763) or (438/786) or (438/787) or (438/791))).CCLS.) and (etch\$3 adj stop\$4)) and ((silicon adj nitride) or sion or (silicon adj oxynitride)) and (silicon adj dioxide) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2003/03/17 11:08 |
| - | 422 | ((((438/624) or (438/634) or (438/637) or (438/737) or (438/738) or (438/740) or (438/743) or (438/744) or (438/761) or (438/763) or (438/786) or (438/787) or (438/791))).CCLS.) and (etch\$3 adj stop\$4)) and ((silicon adj nitride) or sion or (silicon adj oxynitride)) and (silicon adj dioxide)) and ((contact same hole) or via or interconnect\$3) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2003/03/17 11:09 |
| - | 266 | ((((((438/624) or (438/634) or (438/637) or (438/737) or (438/738) or (438/740) or (438/743) or (438/744) or (438/761) or (438/763) or (438/786) or (438/787) or (438/791))).CCLS.) and (etch\$3 adj stop\$4)) and ((silicon adj nitride) or sion or (silicon adj oxynitride)) and (silicon adj dioxide)) and ((contact same hole) or via or interconnect\$3)) and (selective\$2 same etch\$4) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2003/03/17 11:10 |
| - | 175 | ((((((438/624) or (438/634) or (438/637) or (438/737) or (438/738) or (438/740) or (438/743) or (438/744) or (438/761) or (438/763) or (438/786) or (438/787) or (438/791))).CCLS.) and (etch\$3 adj stop\$4)) and ((silicon adj nitride) or sion or (silicon adj oxynitride)) and (silicon adj dioxide)) and ((contact same hole) or via or interconnect\$3)) and (selective\$2 same etch\$4 same stop\$4) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2003/03/17 11:10 |